

# Symposium “Electronique & numérique durables”

Extension of the Life Cycle Analysis method to an R&D environment, based on the study of a prototype use case.

29/11/2024

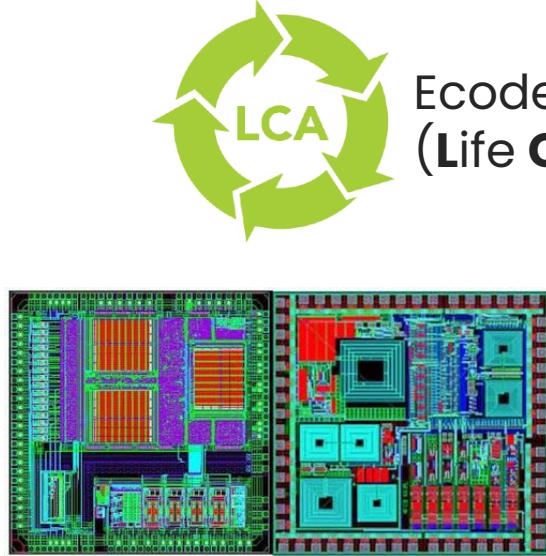
*Makan (Thibault) HALTER*

CEA LIST

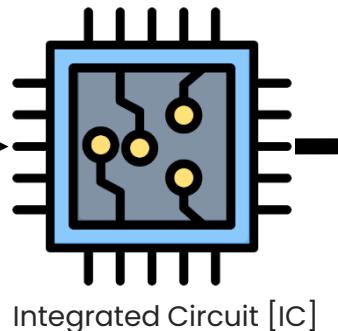


# Introduction

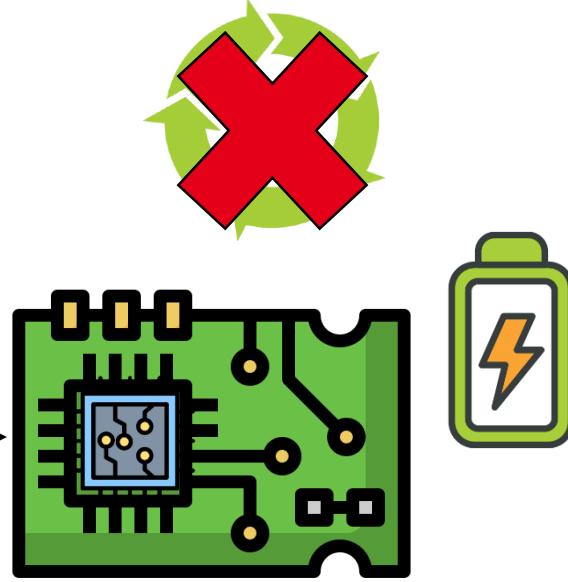
## Analogy : Ingrated Circuit (IC) and building



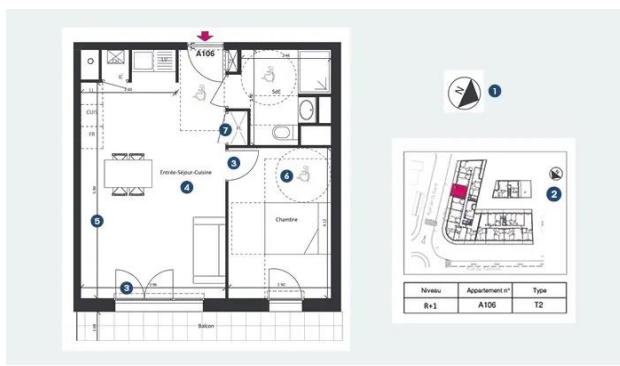
IC Layout



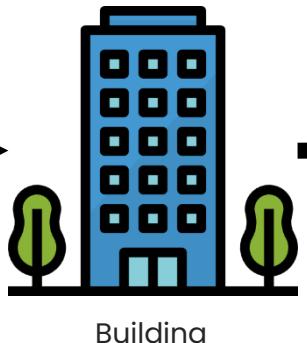
Integrated Circuit [IC]



Integration to a specific environment  
(PCB + capacitors + unknown ICs + battery + captors...)



Architect building plan



Building



Integration to a specific environment  
(Neighborhood)



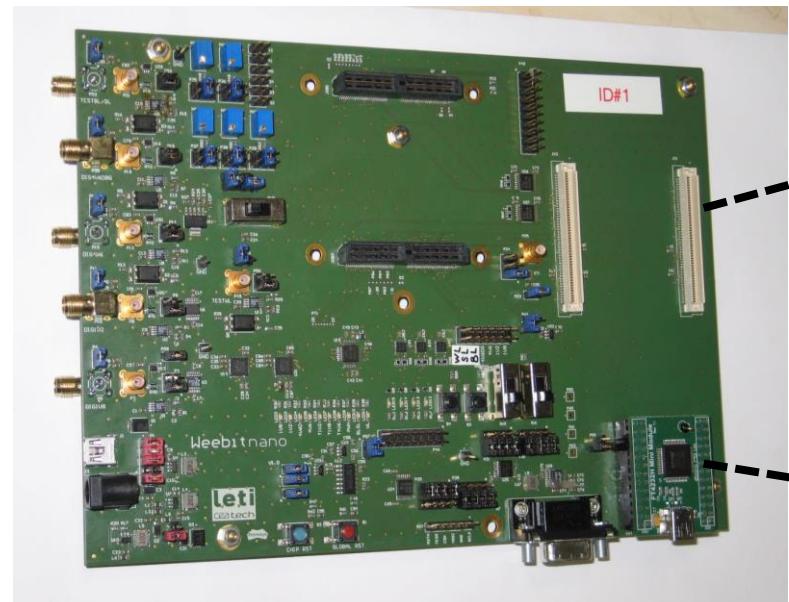
# Introduction

## Objectives :

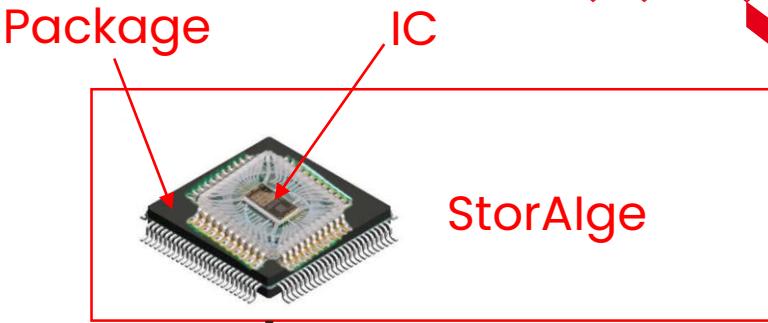
- Define **relevant hypothesis & assumptions** that allow to make **systematic numeric LCA from design**

## 1<sup>st</sup> steps :

- Exploration work from a usecase : StorAige project (CEA LIST)
  - **Prototype testversion** [Extraction & Manufacturing only]



Motherboard



Maha & al.  
"Storage Class Memory with Computing RowBuffer: A Design Space Exploration",  
2021

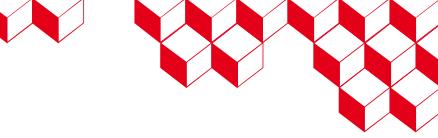


Daughterboard



FTDI Module

# Running a LCA from an electronic design



# Datas from design

Bill of material (BoM)  
>200 components  
(ICs, capacitors,  
resistors, connectors...)

# How to build Life Cycle Inventory from design ?

## Case 1: Non-exhaustive LCA database

**Case 2:**  
Lack of precision in BoM  
and industrial  
datasheets

# LCA software

EIME

## Database [Secondary data]

**CODDE  
Negaoctet**

## Methodology

EF 3.0

# LCA Hypothesis

## Case 1: Non-exhaustive LCA database – Example of Capacitors

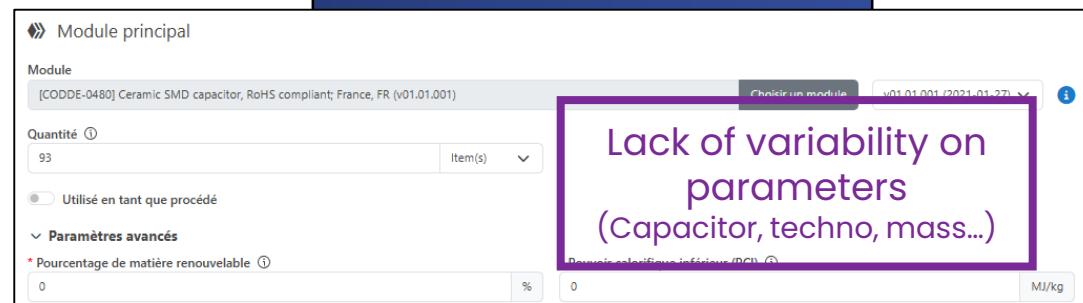
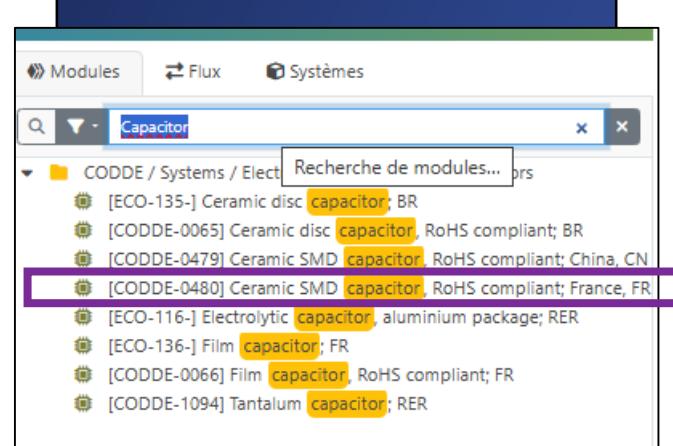
### Datas from design

1uF	1uF	Capacitor (Semiconductor SIM Model)
10uF	10uF	Capacitor (Semiconductor SIM Model)
10uF		Polarized Capacitor TPSA105K020R3000
4.7uF	4.7uF	Capacitor (Semiconductor SIM Model)
10nF	10nF	Capacitor (Semiconductor SIM Model)
100nF	100nF	Capacitor (Semiconductor SIM Model)
330nF	330nF	Capacitor (Semiconductor SIM Model)
2.2uF	2.2uF	Capacitor (Semiconductor SIM Model)
220nF	220nF	Capacitor (Semiconductor SIM Model)
470nF	470nF	Capacitor (Semiconductor SIM Model)



### LCA software

EIME





# LCA Hypothesis

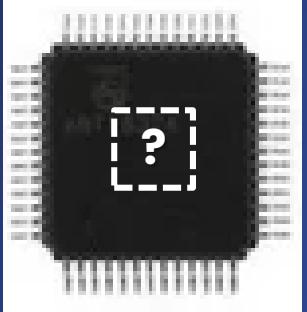
**Case 2:** Lack of precision in BoM and industrial datasheets – Example of unknown ICs

**Datas from design**

**LCA software**

EIME

**IC Dimensions**



**Technology node**

28 nm – 50 masks
45 nm – 42 masks
65 nm – 38 masks
90 nm – 33 masks
130 nm – 29 masks

**Manufacturing location**

China  
Taiwan  
Europe&Usa



# LCA Hypothesis

**Case 2:** Lack of precision in BoM and industrial datasheets – Example of unknown ICs

## Datas from design

### Hypothesis :

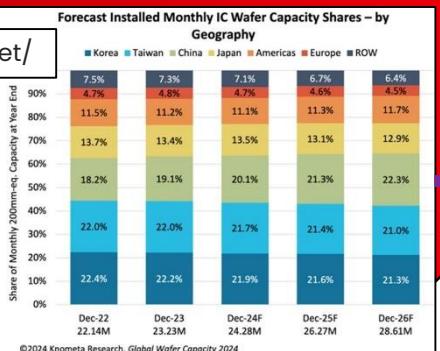
50 % Package dimension

(Uncertainty scenarios :  
20% and 80%)

### Hypothesis :

Mix from **28nm** to **130nm**

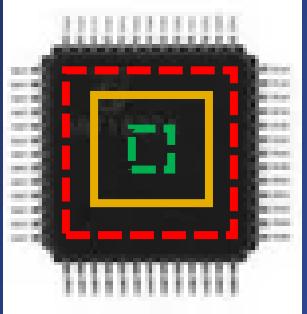
<https://vipress.net/>



## LCA software

EIME

### IC dimension



### Technology node

20 %	28 nm – 50 masks
20 %	45 nm – 42 masks
20%	65 nm – 38 masks
20%	90 nm – 33 masks
20%	130 nm – 29 masks

### Manufacturing location

China : 23%,  
Taiwan&Japan : 61%,  
Europe&USA : 16%

Refers to annual production data from 2022 to 2024



## Concordance of LCA model

➤ Problem :

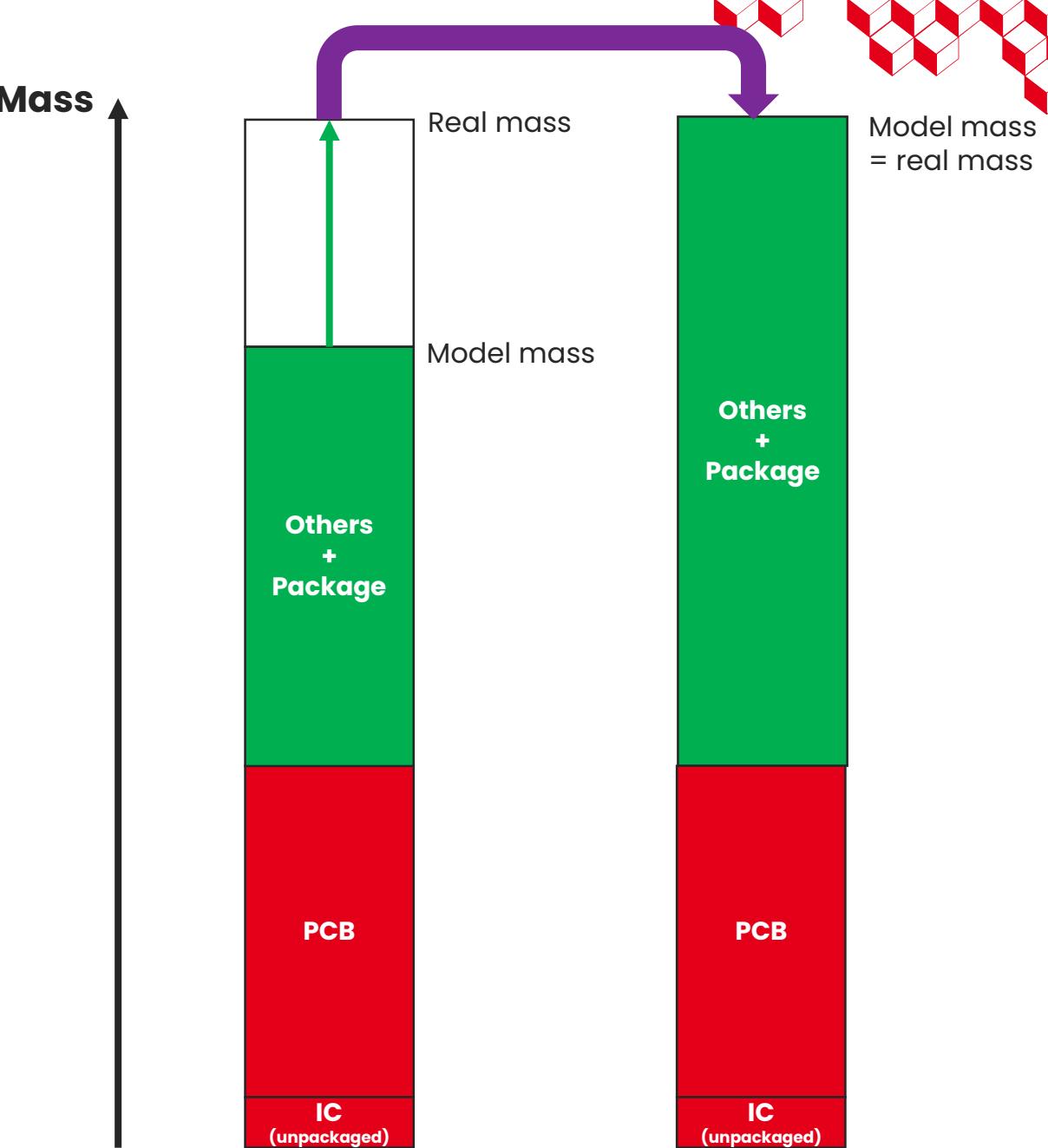
- System mass = **237 g**
- Model mass = **182 g (76%)**

Error might come from **datasheets**

→ **Underevaluation of impacts**

➤ Solution : Bring back model **impacts up to 100%**

**Not concerned : PCB & Digital IC**



# LCA Results

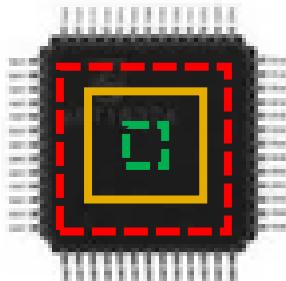
Results for  
**IC Area = 50% PackageSize**

Total mass = 237 g

Emit ~15 kg CO<sub>2</sub>eq  
 (Between 11 kg and 18 kg)

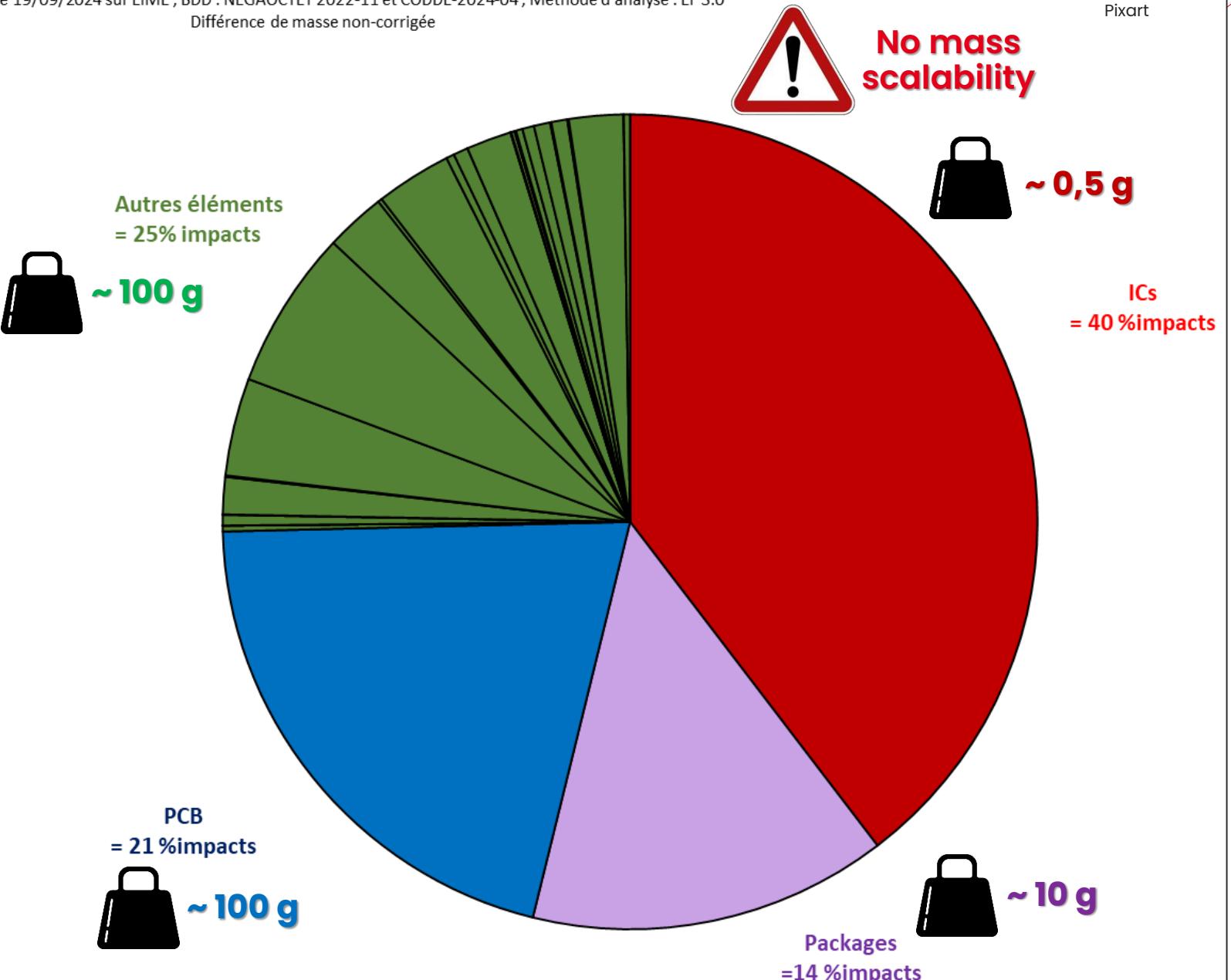
Only for **manufacturing**

Uncertainties :  
**Ic Area = 80% PackageSize**  
**IC Area = 20% PackageSize**



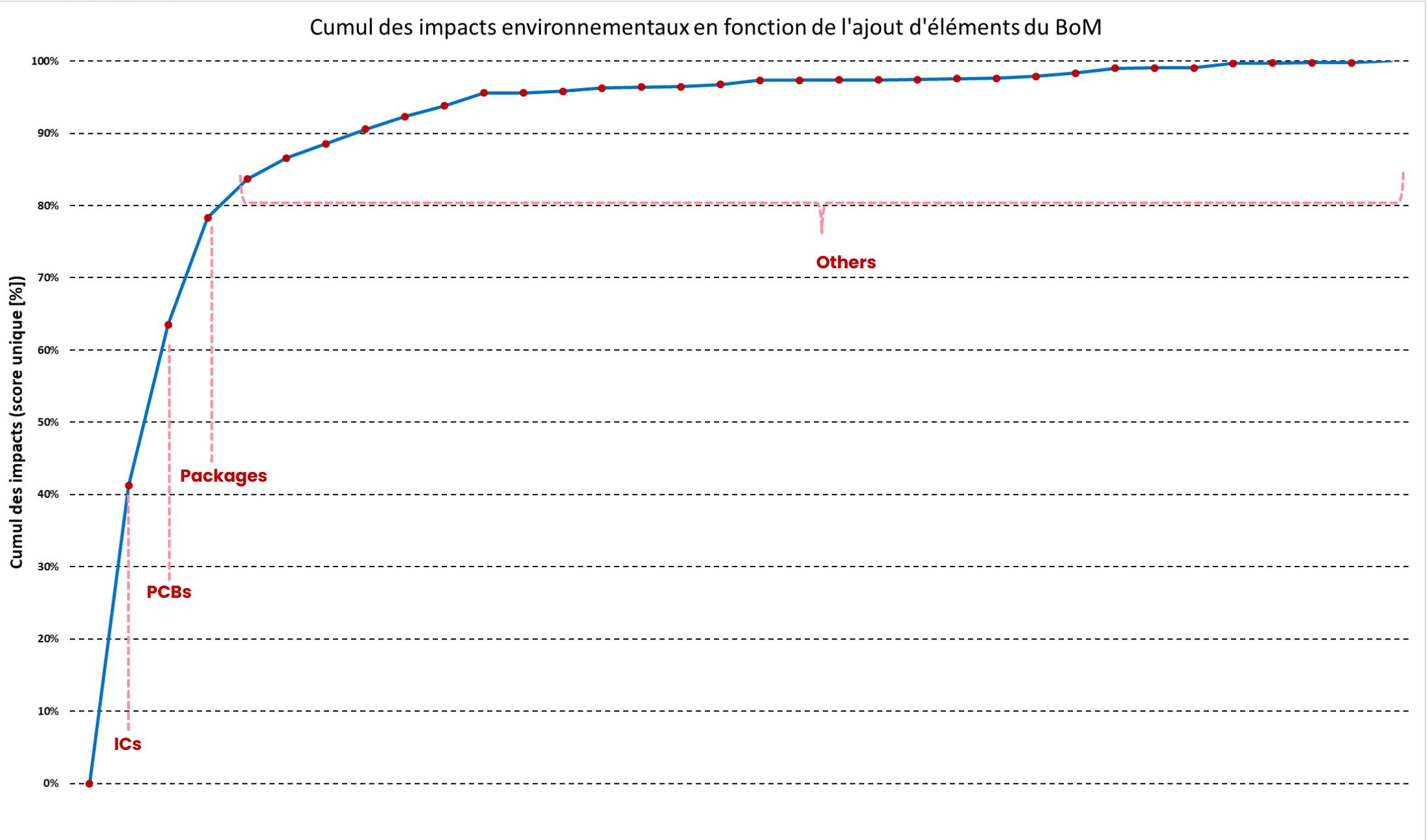
Global impacts = +/- 20%

Résultats (en score unique) Manufacturing système StorAlge  
 ACV réalisée le 19/05/2024 sur EIME, BDD : NEGA/CTET 2022-11 et CODDE-2024-04; Méthode d'analyse : EF 3.0  
 Différence de masse non-corrigée





# LCA Results





# Most valuable datas from design to LCA

	Most valuable data	Remarks / perspective
<b>System Generalities</b>	System total mass	For concordance of model
<b>IC</b>	<b>Technology node</b> or number of Mask <b>IC area</b> ~ IC to package ratio	<b>Main Hotspot</b> (most impactful component)
<b>Package</b>	<b>Package technology</b> <b>Mass</b> Number of input/output	
<b>PCB</b>	PWB Technology (FR2,3,4 or CEM1) Dimensions <b>Number of layers</b>	<b>2<sup>nd</sup> Hotspot</b>
<b>Others components</b>	<b>Bill of Materials</b> <b>Errors from datasheets (mass, dimensions, techno...)</b>	Problem : transposition of BoM to model is the <b>most time consuming</b> and need human intervention



# Future works

## Next steps of the exploration work :

- **Mapping dimension[%] of IC area VS package techno**
- Investigation of a **generics BoMs/cm<sup>2</sup>PCB**
- Extend the LCA to an **industrial version**
- Extend the scope to **usephase, transport** and **end of life**

## Automation of LCA :

- Execute **parametric LCA template** from design informations
- **Appa LCA** : open-source LCA tool to be easily integrated to **IC design flow**
  - Poster of this tool in symposium

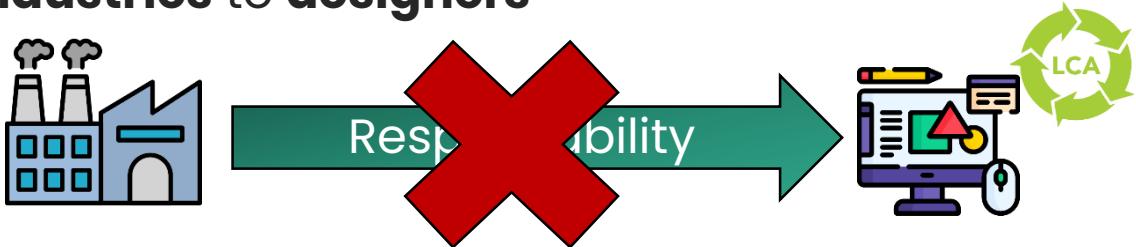


## Attention points



### We shall not

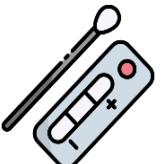
- Transfer the **environmental responsibility** from **industries** to **designers**



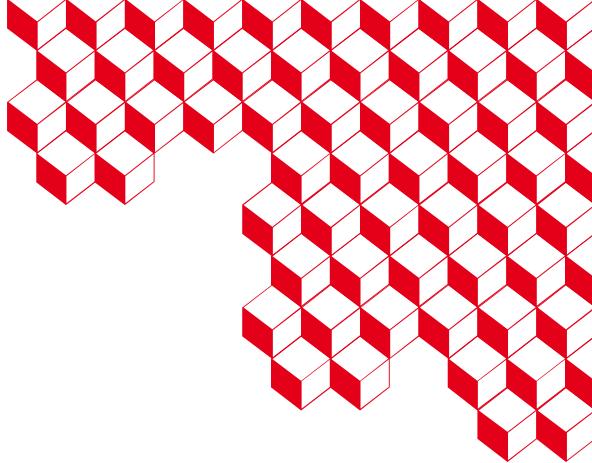
### We have to

- Talk more about **sobriety & performance needs**
- Start to think from **specifications** about **rebound effect** and the **relevance of using a too powerful IC**

Do we really need IC in : rearview mirrors, disposable medical self-test, washbasin, etc. ?



Icon artists :  
Freepik  
Bearicons  
Assia Benkerroum



**Thanks for your attention ♪♪  
Questions ?**

*Acknowledgments :*

*Jérémie BALLESTER, Mikael LE COADOU, Jean-Philippe NOEL, Maria RAMIREZ-CORRALES, Bénédicte ROBIN, Maxime PÉRALTA*

*CEA LIST*